	L #	Hits	Search Text
1	L1	116867	(substrate or wafer) and (mask or reticle)
2	L2	23669	(position$4 or align$4) same (substrate or wafer) same (mask or reticle)
3	L3	78698	(reference) near3 (mark or position or distance)
4	L4	21055	(fiducial or align$4 or reference) near3 mark
5	L5	1443	2 and 3 and 4
6	L6	720	5 and (355/$.ccls. or 356/399-401.ccls.)
7	L7	3713	(detect$3 or sens$3 or measur$5) near3 4
8	L8	295735	(detect$3 or sens$3 or measur$5) near5 (position or location)
9	L9	327626	(calibrat$3 or correlat$3 or (scaling near2 offset))
10	L10	193	6 and 7 and 8 and 9
11	L11	171	@ad<=20010904 and 10

5/30/03